

Abstract Submitted  
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**Unusual electronic states in  $\text{TiO}_2/\text{VO}_2$  (001) multilayers.** VICTOR PARDO, WARREN PICKETT, University of California Davis, PARDO-PICKETT COLLABORATION — Abrupt interfaces between oxides display a wealth of unexpected behavior, and the interface between a band insulator and a Mott insulator is expected to display extra richness. Several multilayered  $\text{TiO}_2/\text{VO}_2$  structures have been studied by ab initio density functional theory techniques, including the thin  $\text{VO}_2$  regime corresponding to the quantum confined Mott insulator.  $\text{VO}_2$  undergoes a metal-insulator transition near room temperature, but when deposited in thin films of thickness smaller than 5 nm, the metal-insulator transition disappears. Our calculations (using the correlated LDA+U method with modest values of U and J) show that the electronic character (metallic versus insulating) changes with the number of  $\text{VO}_2$  layers embedded within insulating  $\text{TiO}_2$  layers: metallic for five  $\text{VO}_2$  layers, semimetallic and half-metallic for three layers, and insulating for a single  $\text{VO}_2$  layer. These trends, and the peculiar nature of the three  $\text{VO}_2$  layer case, will be discussed in some detail.

Warren Pickett  
University of California Davis

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